

## United States Patent and Trademark Office

## \*BIBDATASHEET\*

Bib Data Sheet

## **CONFIRMATION NO. 7282**

SERIAL NUMB 10/624,316	FILING DATE 07/21/2003 10/624,316 RULE		CLASS 250		GROUP ART UNIT 2881		ATTORNEY DOCKET NO. MIT.9922			
APPLICANTS										
Rajesh Menon, Cambridge, MA;										
Dario Gil, Pleasantville, NY; David Carter, Maynard, MA;Henry I. Smith, Sudbury, MA; George Barbastathis, Belmont, MA;										
** CONTINUING DATA **********************************										
"FOREIGN APPLICATIONS "more JB										
IF REQUIRED, FOREIGN FILING LICENSE GRANTED ** SMALL ENTITY ** ** 10/21/2003										
Foreign Priority claimed yes Ino  35 USC 119 (a-d) conditions yes Ino Met after Millowands  Werifled and Acknowledged Examiner's Signature Initials				STATE OR	SHEETS		TOT	AL	INDEPENDENT	
				COUNTRY MA	DRAWING 10		CLAII 14		CLAIMS 4	
ADDRESS Samuels, Gauthier & Stevens LLP Suite 330 225 Franklin Street Boston , MA 02110										
TITLE System and method for maskless lithography using an array of Improved diffractive focusing elements										
						All Fees				
						1.16 Fees (Filing)				
FILING FEE	FEES: Authority has been given in Paper  No to charge/credit DEPOSIT ACCOUNT  No for following:							essing Ext. of		
RECEIVED 482	No	No for tollowing:				☐ 1.18 Fees (Issue)				
						Other				
		. <b>"</b>					Įi l			